

HICUM in commercial simulators

important differences between V2.0 and V2.1

- model parameters
 - **mCf** (and **mCr**), **hjei** were added for III-V and SiGe HBTs
 - **IS** is now officially an alternative to **c10**
 - **zetacx**: temperature dependence of the transit time of parasitic substrate transistor
 - some vendors did not have **hfc** implemented although it was in V2.0
 - **krbi** (noise): was never in DEVICE, but in the documentation, should be dropped generally
- documentation
 - default values have been defined for a *working* and *implementation* set (cf. www)
 - definition of operating point variables (although not directly related to model code)
- Comment from Yo-Chien, Agilent (ADS), regarding element value limitations

"... other vendors may have done something different and customers will see different results and will think that something is not right..."

=> EDA companies to define unified limitations or model has to carry its own limitations

=> the latter will result in more code related burden on model developers

DEVICE (and stand-alone) code

- certain vendors seemed to have gathered different "versions" over the time (from mid nineties)
=> the HICUM model code in DEVICE was cleaned up (adding tunneling current & substrate transistor, changing CJCx implementation corresp. to the doc on www)
- KB, QEL were extended from 4 to 6 digits to obtain close agreement to commercial simulators
- emitter-base breakdown: turning of the calculation above $V_{bep} > 0$ (at forward bias) saves operations and time. Note: a process that shows any non-negligible BE tunneling current of the implemented type will not be used for design.
- transfer current implementation of parasitic substrate transistor:
the following coding error was found (which is of little practical relevance though):
The controlling node potential V_{BxCi} should be changed to V_{BpCi} , consistent with the nodes.
- in HICCR: avoid arithmetic underflow for $T_{f0} * I_{Tf}$ by assigning finite default values to


```
I_TF=1.0E-30
I_TR=1.0E-30
```
- internal base resistance modification due to emitter perimeter minority charge
 - $-Q_{jCi} > Q_{jEi}$ at low forward bias VBE is rare but physically possible (e.g. caused by bad parameter combination)
=> the pole in f_p (and negative r_{Bi}) needs to be avoided under any circumstances.
=> decision: drop Q_{jCi} in the f_p calculation (will not have an impact in practical cases where r_B is of importance)
 - **modified** formulation in procedure HICRBI:


```
IF(Q_f.GT.0.0D0) THEN
  Q_fi=Q_f*f_qi
  f_p=(Q_jEi+Q_fi)/(Q_jEi+Q_f)
```
 - for consistency reasons (frequency & time domain simulation), CHICRBI needs to be modified accordingly:


```
CCCCC operating point dependent quantities
L_1=3
CALL GETLMLB(LM, LB, L_1, L_M, L_B)
K1=L_B+LMODS(L_M, 3)+LMODS(L_M+1, 3)
C_j=PACIR(L_B+2)
```

frequently asked questions and related code fixes

- certain vendor codes
 - Tf equation at high JC: normalization term, $(1 + \sqrt{1 + A_{hc}})$, was implemented as just the factor "2"
 - $Q_{ds} = T_{sf} * its$ to be replaced by $Q_{ds} = T_{sf} * itsf$ (corresp. to (2.1.12-3) on page 64 of manual)
- Internal base resistance
 - Q: Missing derivatives: $dI_{rbi}/dV...$ due to $G_{rbi} = f(V)$
A: the dependence of r_{Bi} vs V within a practical bias range is small and can be neglected. We had done many years ago even simulations of circuits (looking at the small signal input impedance) and did not see any appreciable difference between including and not including the derivatives.
 - CjCi - punch-through voltage
 - The present equation is numerically not suitable for non-physical punch-through voltages outside the range $0 > (V_{PTCi}, V_{PTCx}) \leq 500$
 - the upper limit depends on the implementation (single or double precision): $MAX_EXP=80$ limitation is too low

frequently asked questions and related code fixes (cont'd)

- understanding DEVICE matrix setup for MNA
 - example for inserting a voltage controlled transfer current source in DEVICE

```
CALL CMLDTSG(NBP,NS, NBP,NCI,NS, I_Tsu,-S_suB-S_suS,S_suS)
```

- NBP is the reference node for the controlled current source (any node can be chosen);
- NCI, NS are the nodes, with respect to which the conductances have been calculated.
- I_Tsu contains two exponentials that depend on the potential V_Ci, which is the first node to take the derivative for.
- The derivative terms in the DEVICE code below are more conveniently calculated with respect to nodes Bx and S => derivative w.r.t. node Ci is the sum of the above. Please take a careful look at the following DEVICE code and the definition of the auxiliary variables S_suB and S_suS:

```

a=DEXP(V_BpCi/UM)
b=DEXP(V_SCi/UM)
I_Tsu=IS*(a-b)
CCCCC derivative dI_Tsu/dV_Bx @ VSi, VCi = const
S_suB=IS*a/UM
CCCCC derivative dI_Tsu/dV_S @ VBx, VCi = const
S_suS=-IS*b/UM

```